Special Issue

Sustainable Materials and Chemical Processes-From Concepts to Applications

Message from the Guest Editors

This Special Issue calls for innovative and high-quality reviews, original papers, communications, etc., that concern various aspects of the sustainable development of materials and chemical processes. Experts in the field are then invited to participate in this Special Issue and share their latest achievements aiming to provide breakthrough technology and the next generation of materials for a more sustainable world.

Guest Editors

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Dr. Maria Elisabete Jorge Vieira Costa

Deadline for manuscript submissions

closed (20 September 2023)



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You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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